	Type	L#		Hit	ts	Search Text	DBs	Ti		Co ro m Do m fir en iti	i S	
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3	BF	≀S L	25	152	20633	nitrogen or oxygen or carbon or fluorine or boron	USPATEPO; JPO; Derwe	20 ent;	01/02/11 19:3	1)
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	6	BRS	L8	35	14318	etching same (Ti or TiN or titanium or "titanium nitride")	EPC JPC Der		2001/02/11 19	:51		0
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